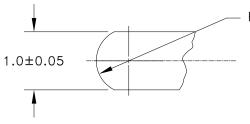
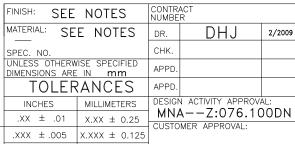
NOTES:

- 1.0.0 ORIENTATIONS
- 1.1.0 WAFER SURFACE IS NORMAL TO Z AXIS WITHIN ±0.3°
- 1.2.0 FLATS.
- 1.2.1 MAJOR FLAT IS NORMAL TO THE -Y AXIS WITHIN ±0.3°.
- 1.2.2 MINOR FLAT IS 90°±1.0° COUNTER-CLOCKWISE FROM THE MAJOR FLAT WHEN VIEWING THE -Z FACE.
- 2.0.0 SURFACES
- 2.1.0 POLISH
- 2.1.1 THE MINUS Z SIDE POLISHED TO 10-5 SCRATCH DIG
- 2.1.2 THE PLUS Z SIDE POLISHED TO 20-10 SCRATCH DIG
- 2.2.0 EDGE
- 2.2.1 ALL EDGES ROUNDED WITH A 0.57±0.08 mm RADIUS
- 2.2.2 NO CHIPS > 0.5mm IN PENETRATION AND 1.0mm IN LENGTH. -
- 3.0.0 FLATNESS
- 3.1.0 WARP < 20 MICRONS
- 3.2.0 TOTAL THICKNESS VARIATION < 6 MICRONS.
- 4.0.0 MATERIAL
 - 5.0 mol% MgO Lithium Niobate
- 4.0.1 Birefringent Phase Matching Temperature for 1064nm laser satisfies 109°C<Tpm<116°C
- 4.0.2 OH-absorption peak location completely shifted to wavenumber 3533.6/cm
- 5.0.0 Shipment includes Certificate of Compliance 97-03044-02-100 detailing Measurements



DETAIL A

 $R=(0.57\pm0.08)mm$



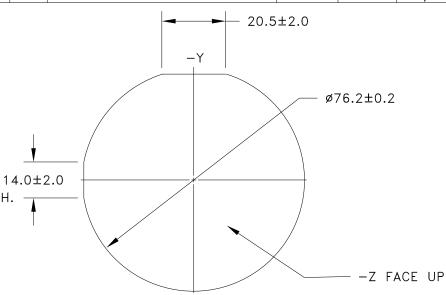
DO NOT SCALE DRAWING

SIDE 1

REVISIONS

DESCRIPTION ECO NO. APPD. DATE

UPDATE COMPANY NAME 20584 SCHOLZ 01/10/14



Z AXIS

Document

01/24/14

Control

В

SH. 1 OF 1

SIDE 2

SCALE:



LNMG 5.0%, 3"ø X .04", -Z Po/Po, -Y&-X FLT, TTV<6um

SIZE A DWG. NO. 97-03044-02

N/A

.XXXX ± .0020 SURFACE FINISH

SEE DETAIL A

ZONEREV

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